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Processing of high entropy alloys with exceptionally good high temperature oxidation properties

Murty, B.S. ; Bhattacharya, Rahul; Kamaraj, M.; Fabijanic, Daniel ; Hodgson, Peter

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LUND UNIVERSITY

PO Box 117
221 00 Lund
+46 46-222 00 00



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Patent Certificate

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आविष्कारकों का नाम / Name of Inventor(s)

1.B.S.MURTHY 2.RAHUL BHATTACHARYA 3.M. KAMARAJ
4.Dr. Daniel Fabijanac 5.Prof.Peter Hodgson

प्रमाणित किया जाता है कि पेटेंटी को, उपरोक्त आवेदन में यथाप्रकटित **PROCESSING OF HIGH ENTROPY ALLOYS WITH EXCEPTIONALLY GOOD HIGH TEMPERATURE OXIDATION PROPERTIES** नामक आविष्कार के लिए, पेटेंट अधिनियम, 1970 के उपबंधों के अनुसार आज तारीख अप्रैल 2016 के सातवें दिन से बीस वर्ष की अवधि के लिए पेटेंट अनुदत्त किया गया है।

It is hereby certified that a patent has been granted to the patentee for an invention entitled **PROCESSING OF HIGH ENTROPY ALLOYS WITH EXCEPTIONALLY GOOD HIGH TEMPERATURE OXIDATION PROPERTIES** as disclosed in the above mentioned application for the term of 20 years from the 7th day of April 2016 in accordance with the provisions of the Patents Act, 1970.



[Signature]

अनुदान की तारीख : 26/10/2023
Date of Grant :

पेटेंट नियंत्रक
Controller of Patents

टिप्पणी - इस पेटेंट के नवीकरण के लिए फीस, यदि इसे बनाए रखा जाना है, अप्रैल 2018 के सातवें दिन को और उसके पश्चात प्रत्येक वर्ष में उसी दिन देय होगी।

Note. - The fees for renewal of this patent, if it is to be maintained, will fall / has fallen due on 7th day of April 2018 and on the same day in every year thereafter.